



### DECLARATION

I, Chieko Kosuge, a staff member of TAIYO, NAKAJIMA & KATO, Eighth Floor, 3-17, Shinjuku 4-chome, Shinjuku-ku, Tokyo 160-0022, Japan, do hereby declare that I am well acquainted with the English and Japanese languages and I hereby certify that, to the best of my knowledge and belief, the following is a true and correct translation made by me into the English language of the documents in respect of Japanese Patent Application No. 2003-113613, that was filed on 18th April 2003 in the name of FUJI PHOTO FILM CO., LTD.

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[DOCUMENT NAME] SPECIFICATION

[TITLE OF THE INVENTION]

## BLACK MATRIX

[CLAIMS]

[Claim 1] A black matrix containing metal fine particles, wherein a volume fraction of the metal fine particles is in a range from 0.05 to 0.70.

[Claim 2] A black matrix according to claim 1, wherein the volume fraction of the metal fine particles is in a range from 0.10 to 0.55.

[Claim 3] A black matrix according to claim 1, wherein the volume fraction of the metal fine particles is in a range from 0.25 to 0.50.

[Claim 4] A method for manufacturing the black matrix according to claim 1, 2 or 3, which method comprises the steps of: using a photosensitive transferring material having a layer and a temporary support, the layer being formed by applying and drying a coating liquid containing the metal fine particles on the temporary support; and transferring the photosensitive layer onto a substrate.

[Claim 5] A method for manufacturing the black matrix according to claim 1, 2 or 3, which method comprises the step of applying and drying a coating liquid containing the metal fine particles on or above a substrate.

[DETAILED DESCRIPTION OF THE INVENTION]

[0001]

[Industrial Field of the Invention]

The present invention relates a black matrix used for a color

filter used for a liquid crystal display device or the like and a method for manufacturing the same.

[0002]

[Prior Art]

A black matrix is a black edge formed on the circumferences of the red, blue and green pixels of a color filter so as to prevent the leaking of light.

In a color filter used for a color liquid crystal display or the like, colored pixel layers (R, G, B) are formed on a transparent substrate, and in order to secure an improvement in display contrast or the like, black matrices are formed in gaps between the colored pixels, R, G, B (red, green, blue). Especially, in an active matrix driving type liquid crystal display device using thin film transistors (TFT), a black matrix having a high light-shielding property (optical density) is required so as to prevent a deterioration in image quality as a result of leakages of current caused by the light of the thin film transistors.

[0003]

It is possible to use metal to manufacture a black matrix having a high light-shielding property. As technique for manufacturing a black matrix with metal fine particles, a plating technique for forming nickel fine particles in a layer has already been disclosed (see patent document 1).

This method, however, has drawbacks, such as complications in precipitating fine particles from a plating solution containing metal ions, complications in the disposal of the waste solution, and many other

environmental considerations.

[0004]

On the other hand, a method of manufacturing a black matrix without using the plating technique is also known, for example, a black matrix formed by using carbon black instead of metal fine particles (see patent document 2).

However, since carbon black has lower optical density per unit of coating amount than that of metal fine particles, if a high light-shielding property and high optical density need to be secured, the film thickness inevitably increases, and once the black matrix has been formed it becomes difficult to form uniform red, blue, and green pixels.

[0005]

Among additional ways of forming a black matrix by means of a plating technique, a following according to which a metal film such as a chrome film is used as a shading layer and, a thin metal film is then formed by a deposition method or by a sputtering method. A photo resist is then applied on the thin metal film, the photo resist layer is then exposed and developed with the use of a photo mask having patterns for a black matrix, and the thin metal film is exposed and then etched. Finally, the resist layer remaining on the thin metal film is exfoliated, and a black matrix is thereby formed (For example, see nonpatent document 1).

Since a thin metal film is used in this method, a high shading effect can be obtained even when the thickness of the metal film is minimal, however, when a vacuum film deposition process, such as a

deposition method or a sputtering method, or an etching process become necessary, problems arise insofar that costs become higher and the burden on the environment can not be lightly dismissed. Moreover, since a metal film invariably has high reflectivity, another problem has been that display contrast is poor in conditions of strong external light. In contrast, another method is to use a low reflection chromium film (a laminated body or the like composed of two layers, a metal chrome layer and an oxidation chrome layer). However, in this case it can not be denied that cost becomes even higher.

[0006]

Further, the hue or the reflectivity of a black matrix containing metal fine particles may be changed as a result of exposure to high temperatures during manufacture, and bubbles may be caused. Thus there is a need in the art for forming an improved black matrix for a liquid crystal display.

[0007]

[Nonpatent document 1]

*"Color TFT liquid crystal display"* PP.218-220, published by Kyoritsu Shuppan Co., Ltd. (April 10, 1997)

[Patent document 1]

Japanese Patent Application Laid-Open (JP-A) No. 5-303090

[Patent document 2]

JP-A No. 62-9301

[0008]

[Problems to be solved by the Invention]

The present invention has been accomplished in response to the problems described above. The invention is directed to provide a thin black matrix which has a high light-shielding performance and can be manufactured at a low cost, and in which no hue or the like is not affected by heat treatment during manufacture.

[0009]

[Means for solving the Problems]

The present inventors have conducted studies in the light of the aforementioned problems, and have discovered that the problems can be solved by setting the volume fraction of the metal fine particles in a black matrix within a specific range. The invention was accomplished based on this finding. Incidentally, the black matrix containing the metal fine particles in the specified range has not been conventionally existent in so far as investigation conducted by the present inventors.

That is, the present invention provides the following:

[0010]

<1> A black matrix containing metal fine particles, wherein a volume fraction of the metal fine particles is in a range from 0.05 to 0.70.

<2> A black matrix of the above <1>, wherein the volume fraction of the metal fine particles is in a range from 0.10 to 0.55.

<3> A black matrix of the above <1>, wherein the volume fraction of the metal fine particles is in a range from 0.25 to 0.50.

<4> A method for manufacturing the black matrix described in the above <1>, <2> or <3>, which method comprises: using a photosensitive transferring material having a layer and a temporary support, the layer



being formed by applying and drying a coating liquid containing the metal fine particles on the temporary support; and transferring the photosensitive layer onto a substrate.

<5> A method for manufacturing the black matrix described in the above <1>, <2> or <3>, which method comprises applying and drying a coating liquid containing the metal fine particles on or above a substrate.

[0011]

[Embodiments]

The present invention provides a black matrix and methods for manufacturing thereof. The black matrix contains metal fine particles, wherein a volume fraction of the metal fine particles is in a range from 0.05 to 0.70 of the same.

Hereinafter, the black matrix and the method for manufacturing the same will be described in detail.

[0012]

[Metal fine particles]

The metal fine particles used in the invention are not limited to a particular metal. Examples of the metals include nickel, silver, gold, platinum, copper or alloy thereof. Silver is preferable in view of chemical stability and cost.

The composition of the metal fine particles used in the invention may be uniform or nonuniform. Examples of the nonuniform compositions include a composition wherein a coating layer made of the composition different from the inside is formed on the surface. The

metal fine particles used in the invention are not limited to a particular shape, and the metal fine particles having various shapes such as sphere, indeterminate form, tabular, cube, regular octahedron and pillar shape can be used.

[0013]

An average particle diameter of the metal fine particles used in the invention is preferably in a range from 1 to 3000nm, and particularly preferably in a range from 10 to 250 nm. When the average particle diameter is less than 1 nm, the absorption wavelength becomes shorter. When the average particle diameter is in excess of 3000 nm, the color may be disadvantageously generated and the optical density may be disadvantageously decreased.

[0014]

A method for manufacturing the metal fine particles used in the invention is not particularly restricted. A known method for manufacturing, for example, a gas phase method such as an evaporation cohesion method and a vapor phase reduction method, and a liquid-phase method such as a liquid phase reduction method can be adopted. The methods are described in "*Leading-edge Trend II in Technology of Ultrafine Particle and Application*", published by S.B. TECHNO-RESEARCH CO., LTD., 2002 in detail.

Examples of known methods for preparation of silver fine particles (colloid silver) include: a method disclosed in U.S. Patent No. 2,688,601, wherein soluble silver salts are reduced by hydroquinone in a gelatin aqueous solution; a method described in German Patent (DE)

No. 1,096,193, wherein hardly soluble silver salts are reduced by hydrazine; a method in which silver ions are chemically reduced in a solution like a method described in U.S. Patent No. 2,921,914, wherein silver is reduced by tannic acid; a method described in JP-A No. 5-134358, wherein silver particles are formed by an electroless plating; and a gas-in evaporation method, wherein bulk metal is evaporated in inert gas such as helium and the bulk metal evaporated is cold-trapped by a solvent.

[0015]

[Volume fraction]

The black matrix of the invention contains a polymer, a monomer, a polymerization initiator and an arbitrary component other than the above components as a binder other than the metal fine particles. A portion of the components may disappear in steps of applying, developing and heat-drying or the like while manufacturing the black matrix. Therefore, in the invention, "volume fraction of the metal fine particles" means the volume fraction of the metal fine particles in the film when the black matrix is formed.

[0016]

For example, the volume fraction of the silver fine particles is calculated according to the following equation.

[0017]

Volume fraction of the silver fine particles = (Coating amount of silver/ 10.5)/film thickness

[0018]

The coating amount of the silver is expressed in  $\text{g}/\text{m}^2$ . The numerical value 10.5 is the density of the silver expressed in  $\text{g}/\text{m}^3$ . Therefore, the value of [Coating amount of silver/10.5] corresponds with the value in which the thickness of the silver is expressed in  $\mu\text{m}$  when the silver is coated as a uniform film. The film thickness is expressed in  $\mu\text{m}$ .

[0019]

In the invention, the volume fraction of the silver fine particles is in a range from 0.05 to 0.70 in the black matrix. The volume fraction is preferably in a range from 0.10 to 0.55, and more particularly in a range from 0.25 to 0.50. When the volume fraction is less than 0.05, the thickness of the black matrix is increased, and thereby a drawback exists in that resulted red, blue and green pixels become nonuniform. When the volume fraction is in excess of 0.70, hue change is disadvantageously caused at the time of being preserved at high temperatures.

[0020]

The black matrix of the invention can be manufactured by a method which includes applying and drying a coating liquid containing the metal fine particles on or above a substrate, or a method which includes forming a recording material having a photosensitive layer and a temporary support, wherein the layer is formed by applying and drying a coating liquid containing the metal fine particles on the temporary support, and transferring the photosensitive layer onto a substrate.

[0021]

[Coating liquid containing metal fine particles]

A coating liquid containing metal fine particles, used in the invention, may contain metal fine particles, and further may contain a polymer and a solvent or the like as a binder.

[0022]

The polymer used in the present invention is preferably one having a protective colloid, and examples thereof include gelatin, polyvinyl alcohol, methyl cellulose, hydroxypropyl cellulose, polyalkylamine, partial alkyl esters of polyacrylic acid, and the like, as well as the compounds disclosed in "Ganryo Jiten (Pigment Book)" (edited by Seishiro ITO, published by Asakura Shoten, 2000).

The amount of the polymer to be used is preferably in the range of 3 to 50 % by weight, particularly preferably 10 to 30 % by weight in the coating liquid.

[0023]

[Solvents]

Known organic solvents can be used as the solvent in the invention. Examples of particularly preferable organic solvents include methyl alcohol, isopropyl alcohol, MEK, ethyl acetate and toluene. Water is also used as a preferable solvent. The solvents may be used in the combination thereof if necessary.

[0024]

[Substrate]

It is preferable that the substrate is a glass substrate used for a

liquid crystal display device or the like. Examples of the glass substrate include known glasses such as a soda glass, a low alkali glass and a non-alkali glass. A thickness of the substrate is preferably in a range from 0.5 to 3 mm, more preferably in a range from about 0.6 to about 2 mm. Glass substrates, described in for example, "*Liquid crystal display engineering introduction*" (Hanani Suzuki, published by The Nikkan Kogyo Shimbun, Ltd., 1998), can be used.

[0025]

(Metal fine particles-containing Coating liquid having photosensitivity)

The coating liquid which contains the metal fine particles of the invention may have photosensitivity. To impart photosensitivity to the coating liquid, a photosensitive resin composition is added. Examples of the photosensitive resin composition include those described in paragraphs 0016 to 0022 and a paragraph 0029 in JP-A No.

10-160926.

When the metal fine particles are used as an aqueous dispersion like the silver colloid, an aqueous photosensitive resin composition is necessary. Examples of the photosensitive resin composition include those described in paragraphs 0015 to 0023 in JP-A No. 8-271727, and additionally, commercially available ones such as "SPP-M20" (trade name, manufactured by Toyo Gosei Co., Ltd.).

[0026]

Method for manufacturing the black matrix

The method according to the present invention comprises the step of applying and drying the coating liquid containing the metal fine

particles on or above the substrate.

A method for forming the pattern of the black matrix is not particularly restricted. Hereinafter, examples of the methods for forming the pattern are described.

(1) A photosensitive coating liquid containing metal fine particles is applied on a substrate and thereby a shading layer (a layer containing the metal fine particles) is formed. Then, patterns are formed by removing non-pattern part of the shading layer by exposure development.

(2) A non-photosensitive coating liquid containing metal fine particles is applied on a substrate and a shading layer is formed. Then, a photosensitive resist liquid is applied thereon, and a resist layer is formed. Then, after patterns are formed on the resist layer by exposure development, a non-pattern part of the shading layer below the patterns is dissolved according to the patterns and the patterns are formed on the shading layer. Finally, the resist layer is removed, and thereby a black matrix is formed.

(3) A coating layer is formed on the part other than patterns of a substrate beforehand. A non-photosensitive coating liquid containing metal fine particles is applied thereon, and a shading layer is formed. Then, the coating layer formed originally and the shading layer formed thereon are removed.

[0027]

In the present invention, the method for applying to the substrate is not limited to a particular method, and examples of the

method include a spin coat method described in JP-A No. 5-224011, a curtain coat method, an extrusion method, and a die coat method described in JP-A No. 9-323472.

In the spin coat method, a coating liquid is dropped on a rotating substrate, and the liquid is spread by centrifugal force.

The curtain coat method is called a flow coat method, and is a kind of slot orifice coating methods. In the method, a coating liquid is dropped in a curtain shape from a slit, and is spread on a substrate. The coating liquid is spread on the substrate by the movement of the slit or the substrate in the horizontal direction, and thereby a uniform thin film is formed.

The extrusion method is called an extrusion coat method, and the coating liquid extruded from the slit is directly spread on a moving substrate.

The coating methods are described in, for example, "*Coating Technology*" (Yuzi Harazaki supervision, published by United Engineering Center Inc., 1983) in detail.

[0028]

A light source used for exposure is selected according to the photosensitivity of a photosensitive resin layer having light-shielding property. For example, a known light source such as an ultrahigh pressure mercury lamp, a xenon lamp, a carbon arc lamp and an argon laser can be used. An optical filter whose optical transmittance of the wavelength of 400nm or more is 2% or less may be used as described in JP-A No. 6-59119.



[0029]

A diluted aqueous solution of an alkaline substance is used as a developer. Further, a developer in which a small amount of an organic solvent being miscible with water is added may be used. Examples of the suitable alkaline substances include alkali metal hydroxides (for example, sodium hydroxide, potassium hydroxide), alkali metal carbonates (for example, sodium carbonate, and potassium carbonate), alkali metal bicarbonates (for example, sodium hydrogen carbonate, potassium hydrogen carbonate), alkali metal silicates (for example, sodium silicate, potassium silicate), alkali metal metasilicates (for example, sodium metasilicate, potassium metasilicate), triethanolamine, diethanolamine, monoethanolamine, morpholine, tetraalkyl ammonium hydroxides (for example, tetramethyl ammonium hydroxide) and trisodium phosphate. The concentration of the alkaline substance is preferably in a range from 0.01 to 30% by weight, and the pH of the alkaline substance is preferably in a range from 8 to 14. According to the nature such as the oxidation of the photosensitive resin layer having light-shielding property according to the present invention or the like, for example, development due to membranous desorption of the present invention can be performed by changing pH or the like of the developer.

[0030]

Examples of suitable organic solvents which are miscible with the water include methanol, ethanol, 2-propanol, 1-propanol, butanol, diacetone alcohol, ethylene glycol monomethyl ether, ethylene glycol

monoethyl ether, ethylene glycol mono-n-butylether, benzyl alcohol, acetone, methyl ethyl ketone, cyclohexanone,  $\epsilon$ -caprolactone,  $\gamma$ -butyrolactone, dimethylformamide, dimethylacetamide, hexamethylphosphoramide, ethyl lactate, methyl lactate,  $\epsilon$ -caprolactam, and N-methyl pyrrolidone. The concentration of the organic solvent which is miscible with the water is generally in a range from 0.1 to 30% by weight.

[0031]

Further, a known surfactant can be added to the developer. The concentration of the surfactant is preferably in a range from 0.01 to 10% by weight.

[0032]

The developer can be used as a bath liquid or a spray liquid. For the removal of a uncured part of a photosensitive resin composition layer having light-shielding property in a solid shape (preferably is a film shape), a method wherein the uncured part is rubbed by a rotating brush or a moist sponge or the like in a developer, or a method wherein atomizing pressure is used when the developer is sprayed is preferable. It is preferable that the temperature of the developer is generally in a range from the vicinity of room temperature to 40°C. Also, washing may be performed after development.

[0033]

Drying step

Heat-drying is performed after developing. That is, a support which has a resin layer (hereinafter, referred to as "photo-cured resin

layer”) optically cured by exposure is heated in an electric furnace and a drying oven or the like, or the photo-cured resin layer is irradiated with an infrared lamp and is heated. A temperature and a time required for heating depend on the composition of the polymerizable composition used and the thickness of the layer formed, and the photo-cured resin layer is preferably heated in a range from about 120 to about 250°C for about 10 to about 300 minutes generally so as to acquire enough resistance to solvents and alkali resistance.

[0034]

(Method using transferring)

The black matrix of the present invention may be manufactured by a method which uses a recording material (hereinafter referred to as “photosensitive transferring material”) having a layer and a temporary support, wherein the layer is formed by applying and drying a coating liquid containing the metal fine particles on the temporary support, and transferring the layer onto a substrate.

A layer (that is, a photosensitive shading layer) manufactured from the coating liquid containing metal fine particles which has photosensitivity, is formed on the temporary support. The film thickness of the photosensitive shading layer is in a range from about 0.3 to 2.0  $\mu\text{m}$ .

It is preferable that the temporary support is chemically and thermally stable and is composed of a flexible substance. Specifically, the temporary support is preferably a thin sheet made of TEFLON®, polyethylene terephthalate, polyethylene naphthalate, polyacrylate,

polycarbonate, polyethylene or polypropylene, or made up of laminates selected from the group consisting thereof. When an alkali-soluble thermoplastic resin layer is formed, it is preferable that the temporary support has excellent peeling property from the resin layer. A suitable thickness of the support is in a range from 5 to 300  $\mu\text{m}$ , and preferably in a range from 20 to 150  $\mu\text{m}$ .

[0035]

It is preferable that an alkali-soluble intermediate layer is disposed between the temporary support and the photosensitive shading layer.

(Alkali-soluble intermediate layer)

The resin composing the intermediate layer is not limited to a particular resin as long as the resin is alkali-soluble. Examples of the resins include polyvinyl alcohol resin, polyvinylpyrrolidone resin, cellulose resin, acrylamide resin, polyethylene oxide resin, gelatin, vinyl ether resin, polyamide resin, and copolymer thereof. Also, an alkali-soluble resin obtained by copolymerizing a monomer having a carboxyl group and a sulfonic group with an alkali-insoluble resin like polyester can be used.

Polyvinyl alcohol is preferable among them. A saponification degree of the polyvinyl alcohol is preferably 80% or more, and more preferably in a range from 83 to 98%.

[0036]

It is preferable that two or more kinds of resins are used in combination in the intermediate layer, and it is more preferable that

polyvinyl alcohol and polyvinylpyrrolidone are used in combination. It is preferable that poly vinylpyrrolidone : polyvinyl alcohol is in a range from 1:99 to 75:25 as mass ratio, and more preferably in a range from 10:90 to 50:50. When the mass ratio is less than 1:99, the deterioration in a condition of the surface of the intermediate layer and the failure of adhesion of the photosensitive layer to the intermediate layer are caused in some cases. When the mass ratio is in excess of 75:25, oxygen impermeability of the intermediate layer may decrease to cause deterioration in sensitivity.

[0037]

Various additives, such as a surfactant, are added to the intermediate layer if necessary.

A thickness of the intermediate layer is preferably in a range from 0.1 to 5  $\mu\text{m}$ , and more preferably in a range from 0.5 to 3  $\mu\text{m}$ . When the above thickness is less than 0.1  $\mu\text{m}$ , the oxygen impermeability may be decreased. When the above thickness is in excess of 5  $\mu\text{m}$ , the time for the removal of the intermediate layer may be increased at the time of developing.

[0038]

A coating solvent of the intermediate layer is not limited to a particular solvent if the above resin can be dissolved in the coating solvent. It is preferable that water is used as the coating solvent and a mixture solvent in which water is mixed with the above water miscible organic solvent is used. Examples of the coating solvents of the intermediate layer include water and mixture solutions including such

as water:methanol = 90:10, water:methanol = 70:30, water:methanol = 55:45, water:ethanol = 70:30, water:1-propanol = 70:30, water:acetone = 90:10, water:methyl ethyl ketone = 95:5 (the ratios are shown in mass ratios).

[0039]

Since the photosensitive shading layer made from the above coating liquid containing metal fine particles is provided, a thin black matrix, which is provided with the shading layer having the high optical density, can be manufactured in the present invention.

[0040]

An optical density is preferably set to 1 or more per 1  $\mu\text{m}$  of the film thickness of the shading layer in the black matrix of the present invention. The black matrix of the present invention has a shading layer manufactured by using a coating liquid containing metal fine particles. The film thickness of the shading layer is preferably in a range from about 0.3 to about 2.0  $\mu\text{m}$ . The shading layer in the black matrix obtained by the present invention is the layer in which metal fine particles are dispersed. Accordingly, even though the shading layer is a thin film, the shading layer has enough optical density.

[0041]

In the present invention, forming a protective layer on the shading layer may be performed after forming the shading layer and before exposing. The protective layer is formed so as to block oxygen and improve sensitivity when exposed. Therefore, it is preferable that the protective layer is the layer mainly composed of resin having oxygen

impermeability, such as polyvinyl alcohol. After the black matrix is formed, the protective layer is removed by development since the protective layer is unnecessary.

[0042]

#### [EXAMPLES]

Based on examples according to the present invention, the invention will be explained in further details. However, the invention should not be limited thereto.

[0043]

#### Example 1

[Preparation of the silver fine particles]

(Production of the silver dispersed slurry)

To 112 g of gelatin, 3.488 g of distilled water was added, and the gelatin was dissolved by heating the mixture obtained up to about 47°C. To the mixture, 4.0 g of calcium acetate and 2.0 g of borohydride potassium were added. Immediately, 6.0 g of silver nitrate dissolved to 1.0 L of distilled water was added to the mixture while rapidly stirred. Distilled water was added to the mixture, and thereby the product of 5.0kg of the final weight was prepared. The product was then cooled close to gel temperature. The product was then made to pass through tiny holes, and was then added to cooled water. Therefore, very minute noodles were formed. The noodles were supplied as an amplification catalyst for generating blue silver on site. Conveniently, the noodles were diluted at a ratio of water/noodle = 1/3 by using the water so as to prevent the noodles from forming melted mass.

To 650 g of borohydride reduction silver nucleus, 6.5 g of mono sulfonic acid hydroquinone potassium and 0.29 g of KCl dissolved in 81 g of distilled water were added. The noodle slurry was cooled to about 6°C. Two kinds of solutions A, B having the following compositions were manufactured in two separate containers.

[0044]

Solution A:

Sodium sulfite (anhydrous)	19.5 g
Sodium bisulfite (anhydrous)	0.98 g
Distilled water	122.0 g

Solution B:

Silver nitrate	9.75 g
Distilled water	122.0 g

[0045]

The solution A and the solution B were mixed, and white precipitation which disappears when keeping stirring was formed. Then, the mixture was immediately added to the noodle slurry while rapidly stirred in a short time (within at 5 minutes). Amplification was progressed at 10°C for about 80 minutes until all the soluble silver salts were reduced on the nucleus. Since the blue slurry particles put in a nylon mesh bag were passed through the slurry in tap water and were washed such that wash water was passed the bag for about 30 minutes, all the salts can be flushed. The washed blue silver dispersed in the gel slurry was drained until the weight of the product is set to 412 g so as to obtain the blue silver dispersed body having the silver of the



density of 1.5% by weight when melted.

[0046]

(Preparation of silver fine particles)

To 5000 g of the silver dispersed slurry obtained through the above method, 25 g of a dispersing agent (trade name: Pyrazole B-90, manufactured by Nippon Oils & Fats Co., Ltd.) and 1000 g of an aqueous solution containing 5% by weight papain were added, and the aqueous solution obtained was preserved for 24 hours at 37°C. The solution was centrifuged at 2000 rpm for about 5 minutes, and the silver fine particles were subsided. After the supernatant liquid of the solution was removed, the solution was washed by distilled water, and gelatin hydrolysate decomposed by enzyme was removed. Then, the sediment of the silver fine particle was washed in methyl alcohol, and the sediment was dried. About 85 g of the agglomerate of the silver fine particle was obtained. 73.5 g of the agglomerate, 1.05 g of the dispersed agent (trade name: Solsperse 20000, manufactured by Avecia Corporation) and 16.4 g of methyl ethyl ketone were mixed. To the mixture, 100 g of the glass beads of 2 mm was mixed, and the mixture obtained was dispersed by a paint shaker for about 3 hours, thereby obtaining a silver fine particles dispersed liquid A-1.

[0047]

(Preparation of the shading layer coating liquid)

The following components were added to and mixed with the silver fine particles dispersed liquid A-1, and thereby a shading layer coating liquid was obtained.

Silver fine particles dispersed liquid A-1	40.0 g
Propylene glycol monomethyl ether acetate	40.0 g
Methyl ethyl ketone	37.6 g
Surfactant (trade name: MEGAFAC F176PF, 20%)	0.2 g
Hydroquinone monomethyl ether	0.001 g
Dipentaerithritol hexaacrylate	

the amount set to the volume fraction of Table 1, 2

Bis[4-N-[4-(4,6-bistrichloromethyl-s-triazine-2-yl)phenyl]carbamoyl]  
phenyl]sebacate 0.1 g

[0048]

(Preparation of the protective layer coating liquid)

Polyvinyl alcohol (trade name: PVA205, manufactured by Kuraray Co.,  
Ltd.) 3.0 g

Polyvinylpyrrolidone (trade name: PVP-K30, manufactured by GAF  
corporation) 1.3 g

Distilled water 50.7 g

Methyl alcohol 45.0 g

The components were mixed, and thereby a protective layer  
coating liquid was obtained.

[0049]

(Application of the coating liquid)

The shading layer coating liquid was applied on a glass  
substrate by using a spin coater such that the optical density is set to  
3.6, and was dried at 100°C for 5 minutes. The protective layer coating  
liquid was then applied thereon by a spin coater such that the dried

film thickness is set to 1.5  $\mu\text{m}$ , and was dried at 100°C for 5 minutes.

[0050]

(Exposure and development)

The application surface side is exposed to light in 70  $\text{mJ}/\text{cm}^2$  exposure light quantity by using an ultrahigh pressure mercury lamp. Then, the development processing was performed by using an alkali developer (trade name: development processing liquid TCD, manufactured by Fuji Photo Film Co., Ltd.) at 33°C for 20 seconds, and thereby a black matrix was obtained.

[0051]

The black matrix obtained was measured and evaluated in the following manner.

(Film thickness measurement)

The film thickness was measured in the following method. The sample on which the shading layer was applied was exposed to light in 70  $\text{mJ}/\text{cm}^2$  exposure light quantity from the application surface side by using an ultrahigh pressure mercury lamp, and the film thickness of the sample was measured by a tracer type surface roughness gauge (trade name: P-1, manufactured by TENKOP company).

[0052]

(Measurement of the volume fraction)

First, the coating amount of silver fine particles was measured in the following method.

The sample on which the photosensitive layer was applied is exposed to light in 70  $\text{mJ}/\text{cm}^2$  exposure light quantity from the

application surface side by using an ultrahigh pressure mercury lamp, and the coating amount of silver fine particles of the sample was measured by a fluorescent X-ray device (trade name: 3370E, manufactured by Rigaku Corporation).

The volume fraction was calculated in the method described above by using the measured value and the film thickness measured in the above method (Film thickness measurement).

[0053]

(Measurement of the optical density)

The optical density of the film was measured in the following method. A shading layer applied on a glass substrate was applied was exposed to light in 500 mJ/cm<sup>2</sup> exposure light quantity from the application surface side by using an ultrahigh pressure mercury lamp. Then, the optical density was measured by using a Macbeth densitometer (trade name: TD-904, manufactured by Macbeth Corporation) (OD). The optical density of the glass substrate was measured in an equivalent method (OD<sub>0</sub>). A value subtracting the value OD<sub>0</sub> from the value OD was adopted as the optical density of the film.

All samples were prepared such that such that the optical density is set to 3.6.

[0054]

(Formation of blue, red, and green pixels and evaluation of bubbles of pixels)

Pixels of each color were formed on a glass substrate on which a

black matrix was formed by using samples R1, G1, B1 in Example-1 described in JP-A No. 2002-4341127. The method for forming pixels described in the Publication was used.

Since the pixels of each color were formed on the ruggedness of the black matrix, bubbles may be introduced between the glass substrate and the pixels of each color. The degree of the generation of the bubbles was measured in the following method.

The number of bubbles was visually counted in 100 pixels each of three colors of the glass substrate, that is, in 300 pixels in total by using an optical microscope.

[0055]

(Color change of the black matrix by heating)

The hue change of a black matrix before and after heat-treating a glass substrate on which the black matrix was formed at 220°C for 2 hours was visually evaluated.

- A No hue change.
- B A little metal luster.
- C A little metal luster within a practically permissible range.
- D Metal luster within a practically damage range.
- E Complete metal luster.

A, B and C are within a practically permissible range.

Table 1 shows the above results.

[0056]

[Table 1]

Sample No	Photosensitive film thickness ( $\mu\text{m}$ )	Volume fraction	Optical density	Bubbles (piece)	Hue change
Comparative Example 1-1	2.9	0.02	3.6	50 or more	A
Example 1-1	0.80	0.08	3.6	12	A
Example 1-2	0.35	0.21	3.6	2	A
Example 1-3	0.18	0.39	3.6	0	A
Example 1-4	0.13	0.52	3.6	0	B
Example 1-5	0.11	0.63	3.6	0	C
Comparative Example 1-2	0.10	0.73	3.6	0	E

[0057]

#### Example 2

(Preparation of the shading layer coating liquid)

The preparation of the shading layer coating liquid was the same as that of Example 1.

(Preparation of the intermediate layer coating liquid)

The preparation of the intermediate layer coating liquid was the same as that of the protective layer coating liquid in Example 1.

(Preparation of the thermoplastic resin layer)

Methyl methacrylate/2-ethyl hexylacrylate/benzil

methacrylate/methacrylate =54/12/5/29 copolymer (The composition ratio shows the mole ratio. The number average molecular weight = 80,000) 58 parts

Styrene/acrylate =70/30 copolymer (The number average molecular weight =7000) 136 parts

A compound obtained by dehydration condensation of an amount of 2

equivalence of octa ethylene glycol mono methacrylate and bisphenol A (plasticizer)(trade name: BPE-500, manufactured by Shin-Nakamura Chemical Co., Ltd.)	90 parts
Fluorine type surfactant (trade name: MEGAFAC F176PF, manufactured by Dainippon Ink And Chemicals, Incorporated)	1 part
Methyl ethyl ketone	541 parts
1-methoxy-2-propanol	63 parts
Methyl alcohol	111 parts

The thermoplastic resin coating liquid was obtained by mixing the above components.

[0058]

(Preparation of the transferring material)

A thermoplastic resin coating liquid was applied on a biaxially stretched polyethylene terephthalate support having the thickness of 75  $\mu\text{m}$  by using a slide coater such that the thickness is set to 15  $\mu\text{m}$ , and was dried at 100°C for 5 minutes. An intermediate layer coating liquid was then applied thereon such that the dried film thickness is set to 1.5  $\mu\text{m}$ , and was dried at 100°C for 5 minutes. In addition, a shading layer coating liquid was applied thereon such that the optical density is set to 3.6, and was dried at 100°C for 5 minutes.

[0059]

(Preparation of the photosensitive material)

A glass substrate and a transferring material were laid such that the glass substrate is brought into contact with a shading layer, and

both of them were laminated by using a laminater (trade name: VP-11, manufactured by Osaka Laminater Co., Ltd.). The lamination process was performed under the conditions of a pressure of 0.8 kg/cm<sup>2</sup> and a temperature of 130°C. Then, a polyethylene terephthalate support was exfoliated.

[0060]

(Preparation of the black matrix)

The application surface side is exposed to light in 70 mJ/cm<sup>2</sup> exposure light quantity by using an ultrahigh pressure mercury lamp. Then, the following development processing was performed, and a black matrix was obtained.

(1) Alkali developer (trade name: development processing liquid TPD, manufactured by Fuji Photo Film Co., Ltd.) development processing (30°C, 40 seconds)

(2) Alkali developer (trade name: development processing liquid TCD, manufactured by Fuji Photo Film Co., Ltd.) development processing (33°C, 20 seconds)

(3) Alkali developer (trade name: development processing liquid TCD, manufactured by Fuji Photo Film Co., Ltd.) development processing (33°C, 20 seconds)

These samples were evaluated in the same manner as Example 1.

Table 2 shows the results.

[0061]



[Table 2]

Sample No	Photosensitive film thickness ( $\mu\text{m}$ )	Volume fraction	Optical density	Bubbles (piece)	Hue change
Comparative Example 2-1	3.1	0.02	3.6	50 or more	A
Example 2-1	0.88	0.07	3.6	8	A
Example 2-2	0.28	0.23	3.6	3	A
Example 2-3	0.19	0.39	3.6	0	A
Example 2-4	0.13	0.53	3.6	0	B
Example 2-5	0.12	0.61	3.6	0	C
Comparative Example 2-2	0.11	0.73	3.6	0	E

[0062]

#### Comparative Example 1

The black matrix of Comparative Example 1 was obtained in the same manner as in Example 1 except for changing the volume fraction of silver fine particles as shown in Table 1 by varying the addition amount of dipentaerithritol hexaacrylate. Table 1 shows the evaluation.

[0063]

#### Comparative Example 2

The black matrix of Comparative Example 2 was obtained in the same manner as in Example 2 except for changing the volume fraction of silver fine particles as shown in Table 2 by varying the addition amount of dipentaerithritol hexaacrylate. Table 2 shows the evaluation.

[0064]

[Effects of the Invention]

The invention can provide a thin black matrix which has a high light-shielding performance and can be manufactured at a low cost, and in which no hue or the like is changed by heat treating at manufacturing.

[DOCUMENT NAME] ABSTRACT OF THE DISCLOSURE

[SUMMARY]

[OBJECT]

To provide a thin black matrix which has a high light-shielding performance and can be manufactured at a low cost, and in which no hue or the like is changed by heat treating at manufacturing.

[ARRANGEMENT]

A black matrix containing metal fine particles, wherein a volume fraction of the metal fine particles is in a range from 0.05 to 0.70.

[SELECTED FIGURE]

None